

See discussions, stats, and author profiles for this publication at: <https://www.researchgate.net/publication/263980526>

Electron Hopping through TiO₂ Powder: A Study by Photoluminescence Spectroscopy

ARTICLE *in* THE JOURNAL OF PHYSICAL CHEMISTRY C · NOVEMBER 2013

Impact Factor: 4.77 · DOI: 10.1021/jp407765r

CITATIONS

5

READS

23

2 AUTHORS, INCLUDING:



[Ana Stevanovic](#)

National Institute of Standards and Technology

7 PUBLICATIONS 52 CITATIONS

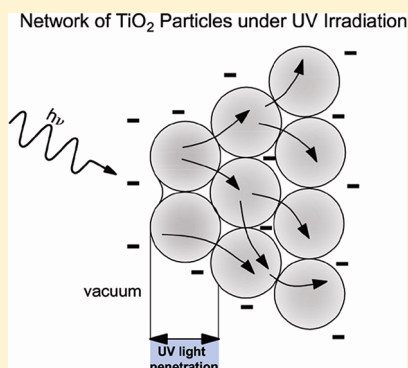
SEE PROFILE

Electron Hopping through TiO₂ Powder: A Study by Photoluminescence Spectroscopy

Ana Stevanovic and John T. Yates, Jr.*

Department of Chemistry University of Virginia, Charlottesville, Virginia 22904, United States

ABSTRACT: Photoluminescence spectroscopy was employed to observe electron transport between TiO₂ particles. Ultraviolet (UV) irradiation (3.88 eV) was shown to positively enhance the photovoltage of TiO₂ particles at the powder surface, causing an enhancement of their photoluminescence (PL) at 530 nm. The charging of the TiO₂ particles on the powder surface by UV irradiation partially discharges in the dark, where the displaced bulk negative charge diffuses back toward the TiO₂ surface. This charge flow partially restores upward band bending, causing the PL intensity to decrease. The rate of the discharging process was used to estimate the electron migration mobility ($\sim 10^{-10} \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$ at 300 K) between TiO₂ particles in the TiO₂ matrix. Electron migration between TiO₂ particles is temperature-dependent with an activation energy of $0.015 \pm 0.008 \text{ eV}$. In addition, it was found that the adsorption of an immobile electron-donor molecule (NH₃), attracts negative charge on the TiO₂ surface which does not exhibit mobility behavior, in contrast to mobile electrons produced by UV. These measurements were carried out in high vacuum in the absence of oxygen and surface impurities detectable by IR spectroscopy.



1. INTRODUCTION

Nanostructures of metal oxides such as TiO₂, ZnO, SnO₂, and Nb₂O₅ have attracted great attention in photovoltaic applications because of their ability to capture and convert sunlight into electrical energy.^{1–4} Among these metal oxides, the most intensively studied material is the n-type TiO₂ semiconductor because of its superior properties, which are heavily utilized for photovoltaic purposes^{5,6} and in photocatalysis.^{7–10} In TiO₂-based photovoltaic devices, the semiconductor particles are sensitized with a light-harvesting dye molecule that serves to deliver photogenerated electrons into a network of interconnected TiO₂ particles. The electrons percolate among interconnected TiO₂ particles and are collected by an electrode. In mesoporous TiO₂, electrons in single crystallites travel by crossing several particle–particle interfaces. In TiO₂ involving 20-nm-sized particles, electrons can cross as many as 50 interfaces in a typical photovoltaic cell.^{11–13} It was shown that the photoconductivity of the mesoporous TiO₂ single-crystal material is 2 orders of magnitude higher than the photoconductivity in a nanometer TiO₂ particle network because of the lower number of particle–particle interfaces. An understanding of charge transport in networks of semiconductor particles is essential for improving the efficiency of photovoltaic devices involving porous semiconducting materials.

Charge transport has been intensively studied by optical and electrical methods such as photovoltage measurements,^{14,15} impedance spectroscopy,¹⁶ Hall effect measurements,^{17,18} photoluminescence,¹⁹ and also modeling.^{20–22} Electron transport in porous TiO₂ occurs under UV exposure, as shown by Ditttrich and co-workers¹⁴ and others,^{23,24} as photogenerated electrons in the conduction band move either freely or by

trapping–detrapping processes from particle to particle across the TiO₂ network. Using tetrahertz time-domain spectroscopy, it was found that the average charge mobility within a TiO₂ nanoparticle is 4 orders of magnitude larger²⁵ than the charge mobility between TiO₂ particles in a TiO₂ matrix that does not contain electrolyte.^{26,27} In an electrolyte-filled TiO₂ matrix, electron mobility between TiO₂ particles is about an order of magnitude faster than that in a porous TiO₂ network.^{28,29}

The surface and electronic properties of porous TiO₂ depend strongly on the presence of adsorbed molecules on the surface, as adsorbates perturb the distribution of electron trap sites, thus affecting electron conductivity. The vast majority of reports on charge-carrier transport in porous materials present measurements performed in air or in different solutions where the surface electronic properties of TiO₂ are altered from those found in vacuum. For example, it was found that in porous nanocrystalline TiO₂, the conductivity of charge carriers in TiO₂ particles increases by 6 orders of magnitude under vacuum conditions due to the removal of adsorbed oxygen.²³ It is postulated that lattice oxygen removal by annealing leads to excess electrons in the surface-oxygen vacancy defect sites. The excess electrons contribute to increased conductivity³⁰ and to upward band bending.³¹ Compared to measurements in air, the experiments presented in this work involve a high level of control of the surface, as the TiO₂ preparation and measurements are conducted under high-vacuum conditions and species adsorbed on the surface are monitored by IR spectroscopy.

Received: August 3, 2013

Revised: October 17, 2013

Published: October 17, 2013



In TiO_2 powder, in the case of n-type material, the production of electron–hole pairs occurs only in the very outer surface region of the powder because of the short penetration depth (~ 20 nm) of the exciting UV irradiation.^{32–35} The UV Irradiation causes the development of a positive surface photovoltage that is confined to the outermost TiO_2 particles in the powder where the particle size is of the same order of magnitude as the light penetration depth. The TiO_2 surface is oxygen-deficient and, therefore, n-type because of the excess electrons in the lattice-oxygen vacancies on the surface, which increase the electronic potential energy near the surface, causing the bands to bend upward. Here, under UV irradiation, energetically preferred electron transport occurs into the bulk from the surface of the particles where the bands are initially bent upward.^{36–38} In this region, electron–hole (e^- – h^+) recombination is retarded as charges are swept away from each other due to the electric field in the first 10–20 nm of the TiO_2 surface. UV irradiation therefore decreases the depletion layer thickness. The positive charge accumulation at the TiO_2 surface during UV irradiation lowers the surface electrostatic potential, causing initially upward-bent bands to flatten. As a result, UV irradiation causes the photoluminescence intensity to be enhanced^{31,32,39–41} as more semiconductor volume within the UV-light penetration depth becomes available for e^- – h^+ recombination.

In this investigation, using photoluminescence (PL) spectroscopy, we observed, under high-vacuum conditions, the change in surface photovoltage upon UV irradiation of interconnected TiO_2 particles. Here, surface negative charge is distributed into the bulk by absorption of energetic photons (3.88 eV) (Figure 1A). Our key finding is that, upon

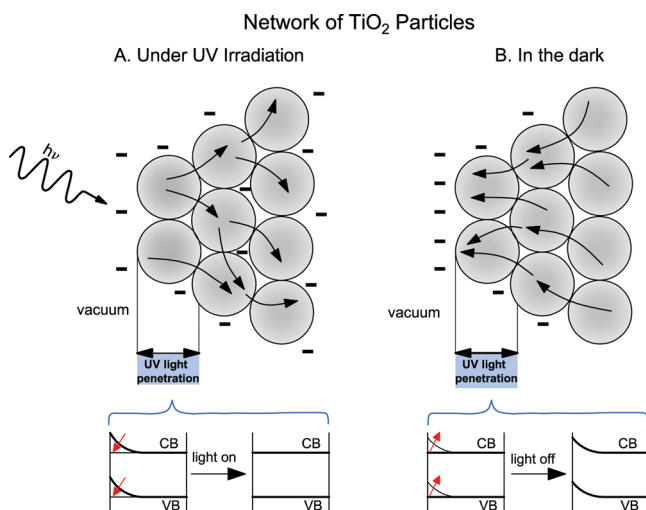


Figure 1. (A) Distribution of surface negative charge into the TiO_2 powder caused by absorption of UV photons and inducing a more positive surface photovoltage on the outer TiO_2 particles, causing band flattening. (B) Diffusion of the bulk negative charge back to the TiO_2 surface in the dark, partially restoring upward band bending.

discontinuation of UV irradiation, some of the negative charge originally distributed in the TiO_2 network returns to the surface of the outermost TiO_2 particle (Figure 1B), partially restoring the upward band bending and reducing the PL intensity. Here, the production of a charged powdered TiO_2 surface by UV irradiation, followed by its discharge in the dark by migration of displaced electrons back to the surface, can be viewed as the

behavior of a planar capacitor. The rate of discharge can be used to estimate the charge mobility as electrons hop from particle to particle if the electric field inducing electron mobility can be estimated. In addition, it was found that this process is temperature-dependent as the rate of electron hopping between particles is enhanced at higher temperatures. Further, we have employed a chemical species, an electron-donor molecule (NH_3), to produce immobilized positively charged species on the TiO_2 surface analogous to the surface charging during irradiation. As expected, upon discontinuation of UV irradiation when adsorbed NH_3 is present, electrons in TiO_2 do not transport in the same manner as observed for electrons when the surface is positively charged by UV photons.

2. EXPERIMENTAL SECTION

The experimental apparatus was described previously.³² In brief, a stainless steel optical cell with CaF_2 windows was employed, allowing both PL and transmission IR measurements to be made on powdered TiO_2 . The base pressure in the high-vacuum stainless steel cell after bakeout was $\sim 3.0 \times 10^{-9}$ Torr as measured by a cold cathode gauge or a quadrupole mass spectrometer (SRS model RGA 200). The TiO_2 powder sample was fabricated as a pressed disk held in a temperature-controlled tungsten grid. The high-vacuum cell was rigidly attached to a small portable high-vacuum system, allowing it to be moved under high vacuum from an infrared spectrometer (Perkin-Elmer Spectrum 100) to an adjacent photoluminescence spectrometer (Perkin-Elmer LS-55), maintaining the cell position accurately constant in both spectrometers. The TiO_2 powder was pressed with 6000 psi into a 0.0095-cm-thick tungsten grid, filling hundreds of window openings (0.022×0.022 cm²) by the creation of a 7-mm-diameter circular spot that could be accurately positioned in the UV or IR optical beam. The mass of the TiO_2 sample was 5.9×10^{-3} g. The sample was held on a tungsten grid that was clamped to a Cu (OFHC) sample holder that was connected to electrical feedthroughs and mounted on the end of a re-entrant Dewar. The temperature of the sample was measured by a 0.0076-cm-diameter K-type thermocouple, spot-welded on the center top of the grid. Temperature control to 0.1 K was achieved using liquid- N_2 cooling and electrical heating. The temperature of the grid could be linearly programmed between 84 and 1000 K by using a data acquisition card (National Instrument, DAC) and feedback from the thermocouple to control the heating current. This allowed for precise isothermal measurements.

The photoluminescence measurements employed 320 ± 10 nm (3.88 eV) incident light from a pulsed Xe source (60 Hz with a pulse width of < 10 μs). The continuous power measured at the sample position was 9.1×10^{-5} J s⁻¹ cm⁻² [1.5×10^{14} photons cm⁻² s⁻¹]. A grating and a 320-nm band-pass filter were employed on the source side. The spectra were obtained using a 15-nm slit width at the excitation side and a 20-nm slit width at the emission side with a scan speed of 500 nm min⁻¹. The PL spectra were detected by an R928 photomultiplier tube covering the 200–900-nm range. For the PL measurements, the sample is positioned 15° off the specular reflection direction of the source light to minimize detection of the reflected incident light from the sample surface and from the CaF_2 window.

The TiO_2 powdered samples employed in this work were provided by Evonik Industries (P-25, formerly Degussa). The P-25 TiO_2 consists of 75% of anatase and 25% rutile phase with particle sizes between 30 and 80 nm and a surface area⁵⁰ of 50

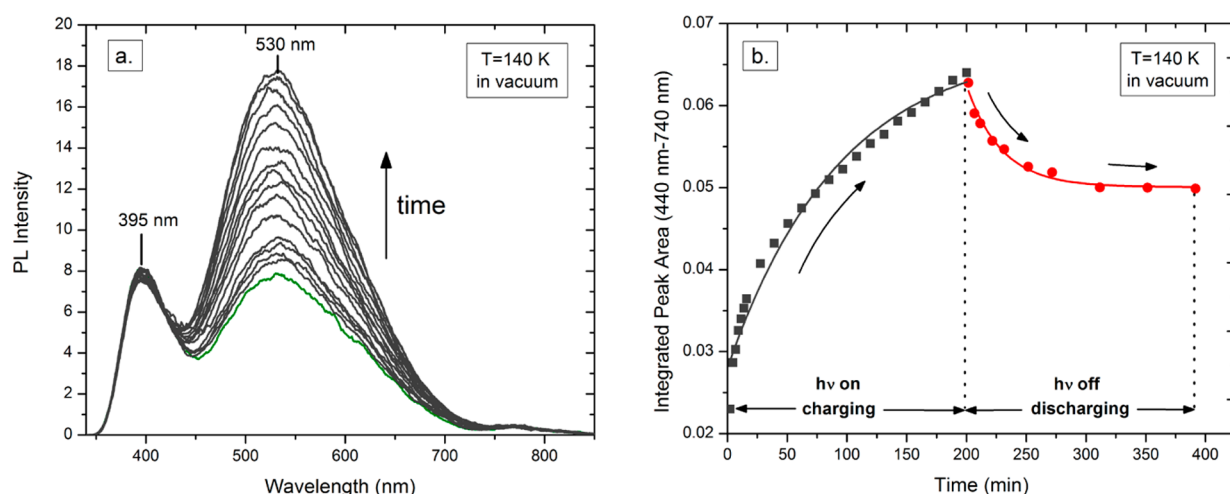


Figure 2. (a) Development of a 530-nm TiO_2 photoluminescence feature during continuous UV irradiation in vacuum at 140 K. (b) Change in PL intensity during and upon discontinuation of UV irradiation in vacuum at 140 K. Black curve shows an exponential increase in PL intensity upon irradiation of TiO_2 particles indicating a decrease in the surface negative charge due to electron hopping then occurs from particle to particle, negatively charging the interior of the TiO_2 network. The red curve shows a decrease in the PL intensity of the TiO_2 particles as negative charge transports from the interior of the TiO_2 powder back to the surface, partially restoring upward band bending.

$\text{m}^2 \text{g}^{-1}$. A water slurry of TiO_2 particles was dried in air at 353 K. Additional adsorbed water was removed by treatment of the pressed sample in vacuum at 650 K for 30 min. Further thermal treatment at 650 K in vacuum followed by treatment in $\text{O}_2(\text{g})$ at 0.5 Torr for 30 min at 650 K was carried out. The sample was finally treated in vacuum at 650 K for 10 min and then cooled to liquid-nitrogen temperatures in vacuum for the experiments. Following this treatment, the IR spectrum of the sample indicated that no OH- and C-H-containing adsorbed species were present at the detection limit of about 1% of a monolayer. The oxygen treatment was shown to effectively remove traces of adsorbed organic impurities that display C-H stretching modes in the 3000 cm^{-1} region.

3. EXPERIMENTAL RESULTS

3.1. Charging and Discharging of the TiO_2 Surface. In Figure 2a, the black spectra with maxima at 530 nm show that the PL intensity from TiO_2 particles increases during long UV exposures using the light in the PL spectrometer to activate long-term changes in the TiO_2 . The peak at 395 nm is an optical artifact and is disregarded.³² In Figure 2b, black points show the development of the 530-nm peak over time. The PL intensity ultimately approaches a near-saturation plateau indicating a near-flat-band condition. Here, the concentration of negative surface charge diminishes as electrons are distributed into the network of TiO_2 particles (charging process), as shown in Figure 1A. In Figure 2b, the red curve shows that the PL intensity decreases upon discontinuation of UV irradiation for 192 min in vacuum (discharging process), as shown in Figure 1B. The PL intensity reaches its minimum value when only a fraction of distributed electrons diffuse from the depth of the powder back to the surface, thereby causing only partial restoration of upward band bending of the outermost particles. These measurements in the dark involve short UV exposures of 45 s each, yielding a measurement of the discharging rate as seen by the drop in the PL intensity, where the long-term influence of the UV light can be disregarded as it is only 2.5% of that used to produce the initial charging curve.

3.2. Electron Migration from Particle to Particle. Figure 3 shows several consecutive charging/discharging cycles of the

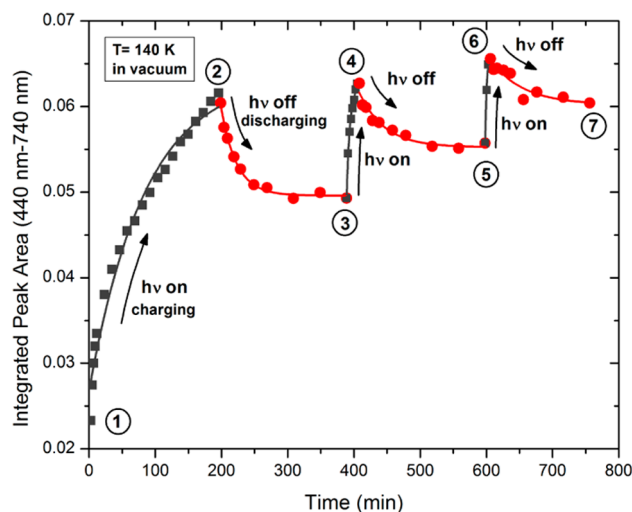


Figure 3. Photoluminescence development upon UV irradiation (gray squares) and relaxation in the dark (red circles) at 140 K in vacuum. During the three UV irradiation cycles (shown by gray squares), the rate of photoluminescence intensity increase yields the slowest development in the first cycle ($k_{1-2} = 2 \times 10^{-4} \text{ s}^{-1}$) and faster development during the second and third irradiation cycles ($k_{3-4} = 3 \times 10^{-4} \text{ s}^{-1}$ and $k_{5-6} = 3 \times 10^{-3} \text{ s}^{-1}$, respectively). Upon interruption of UV light (shown by red circles), the rate of change of the PL intensity decreases as time passes, giving PL decay rates of $k_{2-3} = 7 \times 10^{-4} \text{ s}^{-1}$, $k_{4-5} = 4 \times 10^{-4} \text{ s}^{-1}$, and $k_{6-7} = 3 \times 10^{-4} \text{ s}^{-1}$.

TiO_2 network at 140 K in vacuum. During the UV irradiation cycles, the PL intensity increases (shown by the black curves) as negative surface charge diffuses deeper into the network of TiO_2 particles, leaving less charge on the surface and causing upward-bent bands to flatten (point 2). As previously discussed, the bands flatten as UV light causes electrons to leave the surface of the TiO_2 particles located on the outermost surface of the powder. Upon discontinuation of UV irradiation (shown by the red curve), partial relaxation occurs as the PL intensity exponentially decreases as electrons diffuse back from the bulk onto the TiO_2 surface. The rate of charge diffusion from the surface into the TiO_2 powder bed by UV irradiation increases

as higher levels of PL intensity are produced in successive experiments (black curves) with rate constants of $k_{1-2} = 2 \times 10^{-4} \text{ s}^{-1}$, $k_{3-4} = 3 \times 10^{-4} \text{ s}^{-1}$, and $k_{5-6} = 3 \times 10^{-3} \text{ s}^{-1}$. On the other hand, the rate of charge diffusion from the bulk to the surface of the TiO_2 network in the dark in vacuum, decreases as time passes, with discharge time rates of $k_{2-3} = 7 \times 10^{-4} \text{ s}^{-1}$, $k_{4-5} = 4 \times 10^{-4} \text{ s}^{-1}$, and $k_{6-7} = 3 \times 10^{-4} \text{ s}^{-1}$. The reason for the decreasing rate of discharge is that, during the passage of time in the experiment, electronic charge penetrates more and more deeply into the bulk and becomes unavailable for back-diffusion.

3.3. Adsorbed NH_3 : Immobilization of Surface Charge in Interconnected TiO_2 Particles. We studied the adsorption of the electron-donor molecule NH_3 onto TiO_2 particles to determine whether the deposition of an immobile charged chemical species would show different behavior from the displacement of mobile electrons. Adsorption of NH_3 was performed at 120 K, which is a temperature at which electrons are mobile in TiO_2 . In Figure 4, the green point shows the PL

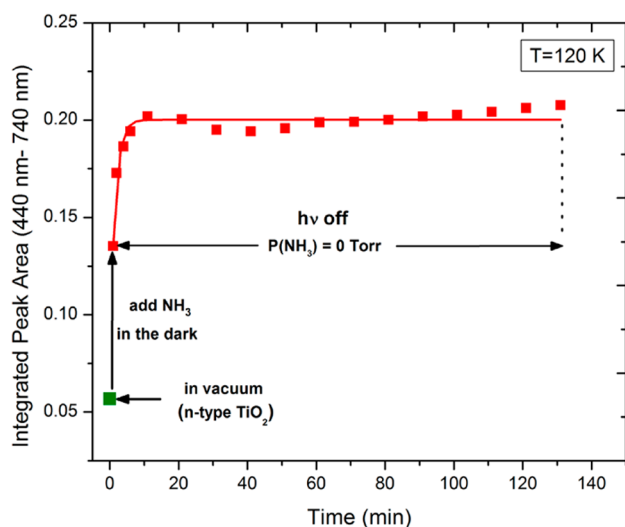


Figure 4. Immobilization of charges by chemical means. Adsorption of NH_3 on n-type TiO_2 surface with upward-bent bands at 120 K in the dark. Upon admission of $\sim 8 \times 10^{16}$ molecules of NH_3 (electron donor molecule), the PL intensity increases quickly as the upward-bent bands of TiO_2 flatten and the PL intensity then remains invariant over time in the dark.

intensity from a clean n-type TiO_2 surface in vacuum at 120 K, which represents an initial upward band-bending condition of the n-type material. Upon admission of $\sim 8 \times 10^{16}$ NH_3 molecules in the dark, the PL intensity initially rises as a result of the flattening of the band. Chemisorbed NH_3 causes the partial cancellation of the local negative-outward surface dipole on the outer TiO_2 n-type particle (as shown by the red points). Following NH_3 adsorption in the dark at 120 K, the PL intensity remains constant in vacuum for 130 min, which implies the presence of a stable surface charge on the TiO_2 particles in the outermost surface.

This experiment strikingly demonstrates the contrasting behavior of mobile electrons as they hop between TiO_2 particles and immobile electrons as they remain attracted by positively charged adsorbate molecules that do not move into the interior of the TiO_2 powder at the temperature employed.³⁶ The sign of the behavior of the PL intensity and the rate of PL intensity change are measures of the mobility, and the direction

of motion of electrons contrasted to the immobility of electrons upon adsorption of positively charged molecules.

3.4. Temperature Dependence of Charge Migration between TiO_2 Particles. In Figure 5, the black points show the normalized PL development under UV irradiation for ~ 184 min in vacuum. Here, the irradiated surface was initially brought to a near-flat-band condition. At 184 min, the UV light was blocked for 120 min at different temperatures, namely, 84, 100, 110, and 140 K. In the dark, the PL intensity exponentially decreases, and the rate of the discharging process increases, with rate constants of $k_{84 \text{ K}} = 1.9 \times 10^{-4} \text{ s}^{-1}$, $k_{100 \text{ K}} = 3.5 \times 10^{-4} \text{ s}^{-1}$, $k_{110 \text{ K}} = 3.9 \times 10^{-4} \text{ s}^{-1}$, and $k_{140 \text{ K}} = 4.6 \times 10^{-4} \text{ s}^{-1}$ as the temperature is increased from 84 to 140 K. Comparing data at all four temperatures, one sees that the rate of charge migration from the TiO_2 interior to the surface is reduced at lower temperatures, as judged by the rate of decay of the PL intensity in vacuum in the dark. Panel b shows the natural logarithm of the rate of charge migration between particles as a function of T^{-1} . Here, the error bars represent a $\pm 20\%$ estimated error of the charge migration rate. The activation energy for the electron-transfer process determined from the plot is $E_a = 0.015 \pm 0.008 \text{ eV}$.

4. DISCUSSION

4.1. Diffusion of Electrons in TiO_2 Powder. The planar powdered TiO_2 sample was pressed into rectangular units with dimensions of $0.022 \text{ cm} \times 0.022 \text{ cm} \times 0.0095 \text{ cm}$ thickness inside a planar tungsten grid. Each small unit is a rectangular block of semiconducting powder with a back and front face exposed to vacuum and with the four edges connecting to tungsten oxide-coated-W boundaries. This corresponds to a material suspended with vacuum interfaces on the front and back and with insulating interfaces at the four edges. The tungsten grid holding the TiO_2 can be considered as an insulating support because of its thick oxide coating.⁴² The geometry of each of the TiO_2 units is that of a suspended rectangular-shaped powder matrix without external contact, and it can therefore be considered as an isolated unit in vacuum.

UV light, incident on the front surface of the powdered matrix and mainly absorbed by the outermost TiO_2 particles, causes electron transport into the interior, producing a positive surface photovoltage (Figure 1) that serves to flatten the upward-bent bands of the outermost particles. This is associated with a PL intensity increase [exponential with time and UV flux (F_{hv})] during long UV light exposures³² in vacuum, as shown in Figure 2. When the light is turned off, the flattened bands start bending upward again, as negative charge inside the TiO_2 powder senses the more “positively” charged surface, and electrons return by slow hopping back to the surface. Because of the slow electron hopping throughout the powder matrix, the rate constant of decay in Figure 3 of the photovoltage in the dark is low and on the order of $4 \times 10^{-4} \text{ s}^{-1}$ at 140 K. The slow hopping of trapped electrons during discharging in the dark in anatase TiO_2 powder was also observed by both electron paramagnetic resonance (EPR) spectroscopy^{43,44} and diffuse reflectance Fourier transform infrared (DRIFT-IR) spectroscopy⁴⁵ under high-vacuum conditions. This rate constant yields an electron mobility that is 7 orders of magnitude smaller than the electron mobility associated with in situ electron-transport processes in TiO_2 single crystals²⁵ and must therefore correspond to charge redistribution due to electron hopping over the surface of the TiO_2 particles and/or between TiO_2 particles. The electron

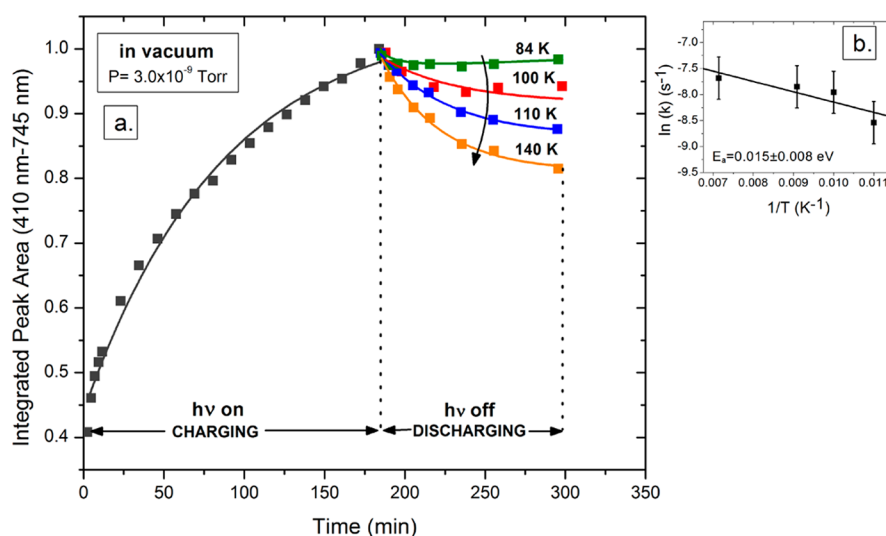


Figure 5. (a) Photoluminescence decay in the dark in vacuum at different temperatures. Black points represent the PL development upon UV irradiation. The TiO_2 surface was prepared to a near-flat band condition, as a saturation PL intensity plateau was almost achieved. Upon interruption of UV light, a PL decrease was observed at different temperatures: 84 K (green), 100 K (red), 110 K (blue), and 140 K (orange). (b) Natural logarithm of the rate of charge migration in the dark as a function of temperature where the extracted activation energy is 0.015 ± 0.008 eV. The data are normalized at the maximum PL intensity.

transport to the interior particles of the powdered matrix when UV light is on is accompanied by back-diffusion of charge to the surface. Hence, the measured rate of change in the PL intensity is the sum of the rate of forward diffusion, driven by UV light, and the rate of back-diffusion of electrons. When UV light is off, the observed PL behavior is directly related only to back-diffusion of electrons from the interior of the TiO_2 matrix back to the outermost TiO_2 particles, which then experience upward band bending and an associated reduction of PL intensity. Here, only a fraction of the bulk electrons migrates to the TiO_2 surface, as judged by the 20% reduction in PL intensity at 140 K, as most of the electrons are distributed deeper in the powder, where long hopping distances reduce electron back-diffusion rates to the surface. Most importantly, in the cyclical experiment of Figure 3, electrons are constantly diffusing into the interior as time passes. Figure 6 schematically shows the distribution of electron density, n_e , as time passes and electrons penetrate by diffusion deeper and deeper into the porous TiO_2 particle bed. The inward electron diffusion rate decreases as the gradient of electron density decreases with time. A back-diffusion rate component also exists in this picture, and as time

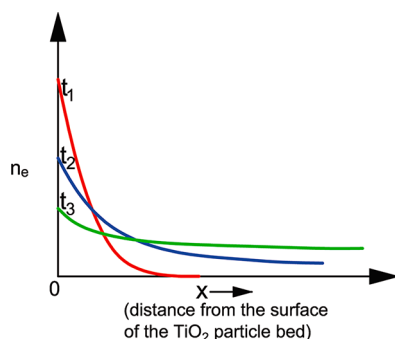


Figure 6. Diffusion of electrons over time in a TiO_2 network. The density of electrons (n_e) at the surface decreases as electrons diffuse deeper into the TiO_2 matrix. As time passes ($t_3 > t_2 > t_1$), more electrons are distributed into the TiO_2 matrix, as shown.

passes, despite the gradient behavior, the back-diffusion rate component will also decrease as electron density spreads to the interior as a result of the longer diffusion paths involved. Because the net rate of electron transport is the sum of the forward and backward component rates, as time passes for charging experiments with the UV irradiation on, the rate of charging (and hence the rate of increase in the PL intensity) will increase, reflecting the decrease in the back-diffusion rate for electrons that have penetrated more deeply into the TiO_2 matrix. Thus, in Figure 3, $k_{5-6} > k_{3-4} > k_{1-2}$. Conversely, as time passes and deeper electron penetration occurs, where the electron path length for back-diffusion increases, the rate of back-diffusion in Figure 3 will decrease and $k_{2-3} > k_{4-5} > k_{6-7}$. The rate component of back-diffusion is a convolution of the electron density gradient and the distances of electron diffusion to reach the surface at $x = 0$.

The behavior of mobile electrons is not observed when immobile adsorbate is used to produce surface charging. Thus, in Figure 4, the adsorption of NH_3 , a donor molecule causing band flattening, is comparable to the production of a positive photovoltage and causes an enhancement of the PL intensity. However, because NH_3 is immobile at 120 K and does not diffuse or desorb away from the surface of the outermost TiO_2 particle,³⁶ the PL decay effect is not observed since “charge” mobility is absent due to the attraction of immobile NH_3 molecules to interior electrons and a constant surface charge is present. This molecule has the expected effect on the PL intensity and is unlike mobile electrons in dynamical behavior.

4.2. Temperature Dependence of Electron Hopping through TiO_2 Particles. An approximate estimate of the effect of temperature on hopping transport was obtained by measuring the discharge decay behavior of the charged TiO_2 surface at various temperatures. Figure 5 shows that, after charging to a near-maximum condition, the decay rate of the discharge process increases as temperature is increased in the range from 84 to 140 K. The Arrhenius plot of these data shows that the activation energy for the decay rate is 0.015 ± 0.008 eV. This activation energy relates to the barrier for particle-to-

particle transport of electrons, where activation energies of 0.030–0.100 eV have been found for such transport process in capped CdSe quantum dots and capped silver nanocrystals.^{46,47} Our measurements cannot discriminate an activated process for transport from electron-trap-to-trap-site on the TiO₂ particle surfaces compared to electron hopping from TiO₂ particle to TiO₂ particle.

4.3. Estimates of Electron Mobility in Hopping through TiO₂ Particles. An approximate estimate can be made of the mobility of the electrons using the time constants for decay of charge and crude estimates for the diffusion lengths and electrostatic potential between the fully charged front face of the TiO₂ powder and the back face. For the fully charged TiO₂ surface in Figure 5, we measured a discharge rate constant at 140 K of $k = 4.6 \times 10^{-4} \text{ s}^{-1}$. Assuming that the electrical potential at the TiO₂ front surface is on the order of 0.1 V,^{31,48} that the thickness of the powder layer is $9.5 \times 10^{-5} \text{ m}$, and that the dielectric constant of powdered TiO₂ is 100,⁴⁹ we estimate that the electric field across the depth of our TiO₂ sample is on the order of 10^3 V m^{-1} . By extrapolation of the Arrhenius plot in Figure 5, we estimate that the 300 K electron mobility is $1 \times 10^{-10} \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$. This value is in satisfactory agreement with Nelson et al.'s value for electron mobility [(1×10^{-11}) – $(1 \times 10^{-10}) \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$] in a porous TiO₂ network obtained under vacuum conditions by time-of-flight measurements at 300 K.²⁷

5. SUMMARY OF RESULTS

The following results were obtained from this study of the production and decay of photoluminescence in a compressed TiO₂ powder of n-type material, working in high vacuum with relatively clean surfaces:

- (1) Discharging rates have been measured as a function of temperature. It was found that TiO₂ powder, when charged by the surface photovoltage effect on its outer surface by exposure to UV light (3.88 eV), will discharge in the dark as electrons originally transported into the TiO₂ bulk are allowed to back-diffuse to the surface.
- (2) The data obtained from cyclical experiments of charging and discharging indicate that the charge transport can be understood by simple considerations of the behavior of a planar slab of TiO₂ powder.
- (3) The activation energy for the electron-transport process was measured to be $0.015 \pm 0.008 \text{ eV}$ in the 84–140 K temperature range.
- (4) An estimate of the electron mobility of $1 \times 10^{-10} \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$ was made for the transport process and the process observed here is very slow compared to *in situ* electron transport processes in crystalline TiO₂. It is assigned to electron hopping either from TiO₂ surface site to surface site, or from nanocrystallite to nanocrystallite in the TiO₂ matrix.
- (5) Although expected changes in PL intensity are achieved by adsorption of an immobile donor molecule, charge mobility effects in the TiO₂ are not seen as for mobile electrons.

AUTHOR INFORMATION

Corresponding Author

*E-mail: johnt@virginia.edu.

Notes

The authors declare no competing financial interest.

ACKNOWLEDGMENTS

We acknowledge with thanks the support of this work by the Army Research Office under Grant 55748CH, as well as a fellowship for Ana Stevanovic from AES Corp. through the AES Graduate Fellowships in Energy Research Program at the University of Virginia.

REFERENCES

- (1) Hagfeldt, A.; Gratzel, M. Light-Induced Redox Reactions in Nanocrystalline Systems. *Chem. Rev.* **1995**, *95*, 49–68.
- (2) Law, M.; Greene, L. E.; Johnson, J. C.; Saykally, R.; Yang, P. D. Nanowire Dye-Sensitized Solar Cells. *Nat. Mater.* **2005**, *4*, 455–459.
- (3) Kamat, P. V. TiO₂ Nanostructures: Recent Physical Chemistry Advances. *J. Phys. Chem. C* **2012**, *116*, 11849–11851.
- (4) O'Regan, B.; Gratzel, M. A Low-Cost, High-Efficiency Solar Cell Based on Dye-Sensitized Colloidal TiO₂ Films. *Nature* **1991**, *353*, 737–740.
- (5) Bach, U.; Lupo, D.; Comte, P.; Moser, J. E.; Weissortel, F.; Salbeck, J.; Spreitzer, H.; Gratzel, M. Solid-State Dye-Sensitized Mesoporous TiO₂ Solar Cells with High Photon-to-Electron Conversion Efficiencies. *Nature* **1998**, *395*, 583–585.
- (6) Gratzel, M. Photoelectrochemical Cells. *Nature* **2001**, *414*, 338–344.
- (7) Linsebigler, A. L.; Lu, G. Q.; Yates, Jr., J. T. Photocatalysis on TiO₂ Surfaces: Principles, Mechanisms, and Selected Results. *Chem. Rev.* **1995**, *95*, 735–758.
- (8) Mills, A.; LeHunte, S. An Overview of Semiconductor Photocatalysis. *J. Photochem. Photobiol. A: Chem.* **1997**, *108*, 1–35.
- (9) Fujishima, A.; Zhang, X.; Tryk, D. A. TiO₂ Photocatalysis and Related Surface Phenomena. *Surf. Sci. Rep.* **2008**, *63*, 515–582.
- (10) Thompson, T. L.; Yates, Jr., J. T. Surface Science Studies of the Photoactivation of TiO₂—New Photochemical Processes. *Chem. Rev.* **2006**, *106*, 4428–4453.
- (11) Crossland, E. J. W.; Noel, N.; Sivaram, V.; Leijtens, T.; Alexander-Webber, J. A.; Snaith, H. J. Mesoporous TiO₂ Single Crystals Delivering Enhanced Mobility and Optoelectronic Device Performance. *Nature* **2013**, *495*, 215–219.
- (12) Ducati, C. Materials Science Porosity in a Single Crystal. *Nature* **2013**, *495*, 180–181.
- (13) Gratzel, M. Dye-Sensitized Solid-State Heterojunction Solar Cells. *MRS Bull.* **2005**, *30*, 23–27.
- (14) Duzhko, V.; Timoshenko, V. Y.; Koch, F.; Dittrich, T. Photovoltage in Nanocrystalline Porous TiO₂. *Phys. Rev. B* **2001**, *64*, 075204.
- (15) Schroder, D. K. Surface Voltage and Surface Photovoltage: History, Theory and Applications. *Meas. Sci. Technol.* **2001**, *12*, R16–R31.
- (16) Dittrich, T.; Weidmann, J.; Koch, F.; Uhlendorf, I.; Lauermann, I. Temperature- and Oxygen Partial Pressure-Dependent Electrical Conductivity in Nanoporous Rutile and Anatase. *Appl. Phys. Lett.* **1999**, *75*, 3980–3982.
- (17) Forro, L.; Chauvet, O.; Emin, D.; Zuppiroli, L.; Berger, H.; Levy, F. High Mobility n-Type Charge Carriers in Large Single Crystals of Anatase (TiO₂). *J. Appl. Phys.* **1994**, *75*, 633–635.
- (18) Yagi, E.; Haseguti, R. R.; Aono, M. Electronic Conduction above 4 K of Slightly Reduced Oxygen-Deficient Rutile TiO_{2-x}. *Phys. Rev. B* **1996**, *54*, 7945–7956.
- (19) Benzaquen, R.; Benzaquen, M.; Charbonneau, S.; Poole, P. J.; Rao, T. S.; Lacelle, C.; Roth, A. P.; Leonelli, R. Evidence from Electrical Transport and Photoluminescence Spectroscopy of a Band of Localized Deep Donors in High-Purity n-Type InP Grown by Chemical-Beam Epitaxy. *Phys. Rev. B* **1994**, *50*, 16964–16972.
- (20) Nelson, J.; Chandler, R. E. Random Walk Models of Charge Transfer and Transport in Dye Sensitized Systems. *Coord. Chem. Rev.* **2004**, *248*, 1181–1194.
- (21) Barzykin, A. V.; Tachiya, M. Mechanism of Charge Recombination in Dye-Sensitized Nanocrystalline Semiconductors: Random Flight Model. *J. Phys. Chem. B* **2002**, *106*, 4356–4363.

- (22) Anta, J. A.; Nelson, J.; Quirke, N. Charge Transport Model for Disordered Materials: Application to Sensitized TiO₂. *Phys. Rev. B* **2002**, *65*.
- (23) Eppler, A. A.; Ballard, I. N.; Nelson, J. Charge Transport in Porous Nanocrystalline Titanium Dioxide. *Phys. E* **2002**, *14*, 197–202.
- (24) Cao, F.; Oskam, G.; Meyer, G. J.; Searson, P. C. Electron Transport in Porous Nanocrystalline TiO₂ Photoelectrochemical Cells. *J. Phys. Chem.* **1996**, *100*, 17021–17027.
- (25) Hendry, E.; Koeberg, M.; O'Regan, B.; Bonn, M. Local Field Effects on Electron Transport in Nanostructured TiO₂ Revealed by Terahertz Spectroscopy. *Nano Lett.* **2006**, *6*, 755–759.
- (26) Dittrich, T.; Lebedev, E. A.; Weidmann, J. Electron Drift Mobility in Porous TiO₂ (Anatase). *Phys. Status Solidi A* **1998**, *165*, R5–R6.
- (27) Aduda, B. O.; Ravirajan, P.; Choy, K. L.; Nelson, J. Effect of Morphology on Electron Drift Mobility in Porous TiO₂. *Int. J. Photoenergy* **2004**, *6*, 141–147.
- (28) Kopidakis, N.; Schiff, E. A.; Park, N. G.; van de Lagemaat, J.; Frank, A. J. Ambipolar Diffusion of Photocarriers in Electrolyte-Filled, Nanoporous TiO₂. *J. Phys. Chem. B* **2000**, *104*, 3930–3936.
- (29) Solbrand, A.; Lindstrom, H.; Rensmo, H.; Hagfeldt, A.; Lindquist, S. E.; Sodergren, S. Electron Transport in the Nanostructured TiO₂–Electrolyte System Studied with Time-Resolved Photocurrents. *J. Phys. Chem. B* **1997**, *101*, 2514–2518.
- (30) Muraoka, Y.; Takubo, N.; Hiroi, Z. Photoinduced Conductivity in Tin Dioxide Thin Films. *J. Appl. Phys.* **2009**, *105*.
- (31) Zhang, Z.; Yates, J. T., Jr. Band Bending in Semiconductors: Chemical and Physical Consequences at Surfaces and Interfaces. *Chem. Rev.* **2012**, *112*, 5520–5551.
- (32) Stevanovic, A.; Buttner, M.; Zhang, Z.; Yates, J. T., Jr. Photoluminescence of TiO₂: Effect of UV Light and Adsorbed Molecules on Surface Band Structure. *J. Am. Chem. Soc.* **2012**, *134*, 324–332.
- (33) Eagles, D. M. Polar Modes of Lattice Vibration and Polaron Coupling Constants in Rutile (TiO₂). *J. Phys. Chem. Solids* **1964**, *25*, 1243–1251.
- (34) Cardona, M. H., G. Optical Properties and Band Structure of Wurtzite-Type Crystals and Rutile. *Phys. Rev. B* **1964**, *137*, A1467.
- (35) Ghosh, G. *Handbook of Optical Constants of Solids*; Academic Press: New York, 1985.
- (36) Stevanovic, A.; Yates, J. T., Jr. Probe of NH₃ and CO Adsorption on the Very Outermost Surface of a Porous TiO₂ Adsorbent Using Photoluminescence Spectroscopy. *Langmuir* **2012**, *28*, 5652–5659.
- (37) Kronik, L.; Shapira, Y. Surface Photovoltage Spectroscopy of Semiconductor Structures: At the Crossroads of Physics, Chemistry and Electrical Engineering. *Surf. Interface Anal.* **2001**, *31*, 954–965.
- (38) Jing, L. Q.; Sun, X. J.; Shang, J.; Cai, W. M.; Xu, Z. L.; Du, Y. G.; Fu, H. G. Review of Surface Photovoltage Spectra of Nano-Sized Semiconductor and Its Applications in Heterogeneous Photocatalysis. *Sol. Energy Mater. Sol. Cells* **2003**, *79*, 133–151.
- (39) Lantz, J. M.; Corn, R. M. Electrostatic Field Measurements and Band Flattening During Electron-Transfer Processes at Single-Crystal TiO₂ Electrodes by Electric-Field-Induced Optical Second Harmonic Generation. *J. Phys. Chem.* **1994**, *98*, 4899–4905.
- (40) Hollingsworth, R. E.; Sites, J. R. Photoluminescence Dead Layer in p-Type InP. *J. Appl. Phys.* **1982**, *53*, 5357–5358.
- (41) Ando, K.; Yamamoto, A.; Yamaguchi, M. Surface Band Bending Effects on Photoluminescence Intensity in n-InP Schottky and MIS Diodes. *Jpn. J. Appl. Phys.* **1981**, *20*, 1107–1112.
- (42) King, D. A.; Madey, T. E.; Yates, Jr., J. T. Interaction of Oxygen with Polycrystalline Tungsten. II. Corrosive Oxidation. *J. Chem. Phys.* **1971**, *55*, 3247–3253.
- (43) Berger, T.; Sterrer, M.; Diwald, O.; Knozinger, E.; Panayotov, D.; Thompson, T. L.; Yates, Jr., J. T. Light-Induced Charge Separation in Anatase TiO₂ Particles. *J. Phys. Chem. B* **2005**, *109*, 6061–6068.
- (44) Ke, S. C.; Wang, T. C.; Wong, M. S.; Gopal, N. O. Low Temperature Kinetics and Energetics of the Electron and Hole Traps in Irradiated TiO₂ Nanoparticles as Revealed by EPR Spectroscopy. *J. Phys. Chem. B* **2006**, *110*, 11628–11634.
- (45) Szczepankiewicz, S. H.; Moss, J. A.; Hoffmann, M. R. Slow Surface Charge Trapping Kinetics on Irradiated TiO₂. *J. Phys. Chem. B* **2002**, *106*, 2922–2927.
- (46) Yu, D.; Wang, C. J.; Wehrenberg, B. L.; Guyot-Sionnest, P. Variable Range Hopping Conduction in Semiconductor Nanocrystal Solids. *Phys. Rev. Lett.* **2004**, *92*.
- (47) Doty, R. C.; Yu, H. B.; Shih, C. K.; Korgel, B. A. Temperature-Dependent Electron Transport through Silver Nanocrystal Superlattices. *J. Phys. Chem. B* **2001**, *105*, 8291–8296.
- (48) Rothschild, A.; Komem, Y.; Levakov, A.; Ashkenasy, N.; Shapira, Y. Electronic and Transport Properties of Reduced and Oxidized Nanocrystalline TiO₂ Films. *Appl. Phys. Lett.* **2003**, *82*, 574–576.
- (49) Parker, R. A. Static Dielectric Constant of Rutile (TiO₂), 1.6–1060 K. *Phys. Rev. B* **1961**, *124*, 1719–1722.
- (50) Ohno, T.; Sarukawa, K.; Tokieda, K. Morphology of a TiO₂ Photocatalyst (Degussa, P-25) Consisting of Anatase and Rutile Crystalline Phases. *J. Catal.* **2001**, *203*, 82–86.